

# JS301-100 Spin Coater

## 100 mm Spin Coater

The JS301-100 benchtop series of small substrate spincoaters is designed for versatility, ease of use and safety in a variety of research and development processes. This spincoater is ideal for processes such as the coating and developing of silicon wafers, glasses, large photomasks, reticles.

- Robust structure
- Easy to use
- Repeatable performance
- Flexibility
- Economical benchtop system

## Specification

Programmable 3 steps, 3 speeds  
Digital RPM meters and timers  
Accuracy  $\pm 1\%$  at set RPM  
Max RPM: 6,000  
Acceleration: 3,000RPM/sec.  
SUS304 body and bowl  
for easy cleaning and chemical resistance  
Drain port  
Clear PC cover for bowl  
Max 100mm diameter & 90x90mm plate  
Standard dry vacuum pump: 100 liter/ min, 0.5 ATM  
Standard sample chuck  
Dimension 350W x 450D x 275H mm  
220VAC, 60Hz, 3 amp  
Weight: 20 Kg

